Press Release

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Oxford Instruments celebrates order from prestigious new university in Saudi Arabia

Oxford Instruments' FlexAL atomic layer deposition tool

Oxford Instruments is pleased to announce a substantial multi-system order from the newly built King Abdullah University of Science and Technology (KAUST) in Saudi Arabia. This large order comprises multiple plasma etch, deposition & growth systems.

These tools will equip the Nanofabrication Core research facility, and include key Oxford Instruments Plasma Technology (OIPT) systems including several Plasmalab®System100 tools for RIE and ICP etch, and PECVD; and a FlexAL® atomic layer deposition tool.

Oxford Instruments has extensive experience in supplying multi-system installations to both the academic and industrial sectors, a key recent example being Southampton University, UK where OIPT has recently installed a number of its tools in its new cleanroom research facility.

Dr. Mohamed Samaha, VP Research Development at KAUST, comments, "This equipment is for our Nanofabrication Core Lab, and comprises tools for nano-material fabrication incorporating etching, deposition and growth. These will make our core labs among the most advanced in the world. Researchers at KAUST will be able to utilize these tools in the clean room for the manufacture of nano-materials to advance the research agenda at KAUST."

Mark Vosloo, Sales Director for OIPT is delighted with the order, "This significant order from a major Middle Eastern facility with a strong commitment to nanofabrication research is clearly excellent business for OIPT. We are confident this is the start of a long relationship, and are delighted to be involved at the inception of KAUST University."

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Issued for and on behalf of Oxford Instruments Plasma Technology Limited

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Notes to editors

About Oxford Instruments plc

Oxford Instruments designs, supplies and supports high-technology tools, processes and solutions with a focus on physical science, bioscience, environmental and industrial research and applications. It provides solutions needed to advance fundamental nanoscience research and its transfer into commercial nanotechnology applications. Innovation has been the driving force behind Oxford Instruments' growth and success for over 40 years, and its strategy is to effect the successful commercialisation of these ideas by bringing them to market in a timely and customer-focused fashion.

The first technology business to be spun out from Oxford University over forty years ago, Oxford Instruments is now a global company with over 1,300 staff worldwide and a listing on the London Stock Exchange (OXIG). Its objective is to be the leading provider of new generation tools and systems for the Physical Science and Bioscience sectors.

This involves the combination of core technologies in areas such as low temperature and high magnetic field environments, Nuclear Magnetic Resonance, X-ray electron and optical based metrology, and advanced growth, deposition and etching. Our products, expertise, and ideas address global issues such as energy, environment, terrorism and health and are part of the next generation of telecommunications, energy products, environmental measures, security devices, drug discovery and medical advances.

About Oxford Instruments Plasma Technology

Oxford Instruments Plasma Technology offers flexible, configurable process tools and leading-edge processes for the precise, controllable and repeatable engineering of micro- and nano-structures. Our systems provide process solutions for nanometre layer epitaxial growth of compound semiconductor material, etching of nanometre sized features and the controlled growth of nanostructures. These solutions are based on core technologies in plasma-enhanced deposition and etch, ion-beam deposition and etch, atomic layer deposition and hydride vapour phase epitaxy. Products range from compact stand-alone systems for R&D, through batch tools and up to clustered cassette-to-cassette platforms for high-throughput production processing.

About KAUST

King Abdullah University of Science and Technology (KAUST) is being built in Saudi Arabia as an international, graduate-level research university dedicated to inspiring a new age of scientific achievement in the Kingdom that will also benefit the region and the world. KAUST is the realization of a decades-long vision of the Custodian of the Two Holy Mosques, King Abdullah bin Abdulaziz Al Saud.

KAUST's advanced nanofabrication core facility will integrate classic semiconductor tools and processes with biological, chemical, and medical substrates to support research in electronic and photonic devices, micro-electromechanical devices, advanced materials processing, and biotechnology devices.